U.S. DEPARTM PATENT AND T	ENT OF RADE! MATI		₹E	Attorney Docket No.: SGL 02/10 Appl. No.:  Applicant: BODO BENITSCH  Filing Date: July 10, 2003 Group Art Unit:					
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	A	Α	5,432,253	07/11/95	<del>                                     </del>	J GE NOG	00.00	<u> </u>		
4		В	2001/0051258 A1	12/13/01	Hanzawa et al.					
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.